

Please amend the specification as follows:

Delete par. 98 and replace it with:

[0098] Thus, in the skeleton, concentration of each non-MPD element in the off tie-line style can vary continuously and independent of the other non-MPD elements within the range between $M_{n,T}$ (when $R_n = 0$) and $M_{n,s}$ (when $R_n=1$). When for each non-MPD element $R_n=0$, then the skeleton composition is identical to the basic method, and the infiltrant composition will also be the same as the basic method infiltrant. When for each non MPD element, $R_n=1$, then the skeleton composition is identical to the near tie-line method, and the infiltrant composition will also be the same as the near tie-line infiltrant.